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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/847,111	05/02/2001	Ya-Chan Cheng	148693.00359	5405
7590	05/21/2004		EXAMINER	
Thomas T. Moga, Esq. Dickinson Wright PLLC 1901 L Street NW Suite 800			STOCK JR, GORDON J	
			ART UNIT	PAPER NUMBER
			2877	
Washington, DC	20036		DATE MAILED: 05/21/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
Office Action Summany	09/847,111	CHENG, YA-CHAN	
Office Action Summary	Examiner	Art Unit	
	Gordon J Stock	2877	
The MAILING DATE of this communication ap Period for Reply	ppears on the cover sheet	with the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.  after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a rep.  - If NO period for reply is specified above, the maximum statutory period.  - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may ply within the statutory minimum of t will apply and will expire SIX (6) M te. cause the application to become	a reply be timely filed  hirty (30) days will be considered timely.  DNTHS from the mailing date of this communic	ation.
Status			
1) Responsive to communication(s) filed on 26 F	February 2004.		
	s action is non-final.		
3) Since this application is in condition for allowa		atters, prosecution as to the merit	s is
closed in accordance with the practice under			0.0
Disposition of Claims			
4)⊠ Claim(s) <u>1-7,9-15 and 17-23</u> is/are pending in	the application		
4a) Of the above claim(s) is/are withdra	• •		
5) Claim(s) is/are allowed.	*		
6) Claim(s) 1-7, 9-15, and 17-23 is/are rejected.		,	•
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/o	or election requirement		
Application Papers	*		
9) The specification is objected to by the Examine			•
10) ☐ The drawing(s) filed on is/are: a) ☐ acc	•		
Applicant may not request that any objection to the	-		
Replacement drawing sheet(s) including the correct			
11) ☐ The oath or declaration is objected to by the Ex	xaminer. Note the attach	ed Office Action or form PTO-152	2.
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:		· ·	
1. Certified copies of the priority document			
2. Certified copies of the priority document			
3. Copies of the certified copies of the prio		n received in this National Stage	
application from the International Burea			
* See the attached detailed Office action for a list	of the certified copies no	t received.	
Attachment(s)			
Notice of References Cited (PTO-892)     Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview	Summary (PTO-413)	
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	5) Notice of	(s)/Mail Date Informal Patent Application (PTO-152)	
Paper No(s)/Mail Date	6)		
U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04) Office Ac	ction Summary	Part of Paper No./Mail Date 2004	 0517

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#### **DETAILED ACTION**

#### Claim Rejections - 35 USC § 112

- 1. The following is a quotation of the second paragraph of 35 U.S.C. 112:
  - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 2. Claim 1-23 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Specifically, in regards to claims 1, 9, and 17, the term following "a lens" "to measure said wafer and said datum slice" is indefinite, for it is unclear as to how a lens measures.

Clarification is required. Claims 2-8, 10-16, and 18-23 are rejected for depending upon a rejected base claim.

### Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-4, 6, 7, 9-12, 14, 15, 17, 19-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Elliott et al. (5,669,979) in view of Kilgore et al. (6,200,412) and Harwood et al. (5,237,267) further in view of Rose et al. (5,931,721).

As for claims 1-4, 6, 7, 9-12, 14, 15, 17, 19-23, Elliott in a photoreactive surface processing device discloses the following: a stage with chuck (Fig. 15, 436, 476, 440); a lens (430 of Fig. 15); a gas supplier with a first nozzle (Fig. 15: 434; Fig. 16); first tube is suggested

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from Fig. 16, a transport slot with an exhaust/evacuation system comprising an evacuation valve and mechanical pump, the gas-extracting motor (Figs 15 and 16); a first flow regulating valve on first nozzle (Fig. 16: 482); an inert gas, helium and nitrogen (Fig. 11: input gas and helium). As for a datum platen, the wafer itself is the origin of the data and placed with a chuck. Kilgore in a cvp system teaches that chucks and platens are functional equivalents for wafer support (col. 2, lines 12-13). Therefore, it would be obvious to one skilled in the art at the time to use a platen rather than a chuck, for they are interchangeable as equivalent support structures for wafers. In addition, Harwood in a wafer probe station having auxiliary chucks teaches that multiple chucks should be used in order to accommodate systems for calibration substrates (col. 1, line 55-67; col. 2, lines 1-15). Therefore, it would be obvious to one skilled in the art to have the system also comprise a chuck/platen for other substrates such as calibration substrates for calibrating the system. As for a second nozzle, Elliott is silent. However, Rose in an aerosol surface processing system discloses two nozzles opposing each other to improve wafer-cleaning performance (col. 10, lines 59-67; col. 11, lines 1-10; Fig. 5). Therefore, it would be obvious to one skilled in the art at the time the invention was made to have two nozzles to enhance wafer-cleaning performance. As for a second tube and a second gas-regulating valve, Rose discloses this (Fig. 5) in order to deliver the second flow of gas to the system and to regulate its delivery pressure.

As for a third tube for the extracting apparatus, Elliott shows this (Fig. 16: between 445 and 446.)

5. Claims 5, 13, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Elliott et al. (5,669,979) in view of Kilgore et al. (6,200,412) and Harwood et al. (5,237,267) further in view of Rose et al. (5,931,721) further in view of Danese (6,272,768).

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As for claims 5, 13, and 18, Elliott in view of Kilgore, Harwood, and Danese disclose everything as above (see claims 1, 9, and 17 above). However, Elliott is silent concerning a venturi structure for the mechanical pump. Danese in an apparatus for treating something in UV light teaches that venturi pumps are typical vacuum pumps for withdrawing fluids (col. 7, lines 5-25). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the system may comprise a venturi structure for typical vacuum pumps for withdrawal of fluids comprise venturi effect pumps.

## Response to Arguments

6. Applicant's arguments with respect to the claims have been considered but are moot in view of the new ground(s) of rejection.

#### Fax/Telephone Numbers

If the applicant wishes to send a fax dealing with either a proposed amendment or a discussion with a phone interview, then the fax should:

- 1) Contain either a statement "DRAFT" or "PROPOSED AMENDMENT" on the fax cover sheet; and
  - 2) Should be unsigned by the attorney or agent.

This will ensure that it will not be entered into the case and will be forwarded to the examiner as quickly as possible.

Papers related to the application may be submitted to Group 2800 by Fax transmission. Papers should be faxed to Group 2800 via the PTO Fax machine located in Crystal Plaza 4. The form of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (November 15, 1989). The CP4 Fax Machine number is: (703) 872-9306

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gordon J. Stock whose telephone number is (571) 272-2431. The examiner can normally be reached on Monday-Friday, 10:00 a.m. - 6:30 p.m.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

gs

May 17, 2004

Zandra V. Smith Primary Examiner

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